

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

: **EXPEDITED PROCEDURE**

PEI-REN JENG

: Response Under 37 CFR 1.116

Serial No.: 09/729,833

: Group Art Unit: 2823

: Examiner: Hsien-Ming Lee

Filed: December 6, 2000

:

For: METHOD FOR PATTERNING A DUAL DAMASCENE
WITH RETROGRADE IMPLEMENTATIONAMENDMENT AND RESPONSE UNDER RULE 1.116Honorable Commissioner for Patents
Washington, D.C. 20231

Sir:

This paper is in response to the Final Official Action mailed July 17, 2002. In that Official Action, claims 51, 53, 54 and 62 are rejected under 35 U.S.C. 112, second paragraph; and further, claims 51 and 63 are rejected under 35 U.S.C. 102 (e) ; and further, claims 52-62 are rejected under 35 U.S.C. 103 (a) ; and further, claims 55, 58 and 60 are objected. Kindly amend and reconsider the application in accordance with the following particulars:

IN THE CLAIMS:

Claims 51, 53, 54, 55, 58, 60 and 62 have been amended as follows:

51. (Amended) A method for forming a dual damascene opening,

#5/BINE
10/21/02
th
RECEIVED
OCT 21 2002
TECHNOLOGY CENTER 2800